# Development and performance of a pixel chip for the readout of GEM detectors for high-rate particle tracking

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Abstract: We report the R&D program underway at CCNU to develop a pixel chip for the readout of GEM detectors appropriate for use in the CSR external-target experiment (CEE) at HIRFL for beam monitoring. The chip offers simultaneous Time over Threshold (ToT) and Time of Arrival (ToA) measurements, with an event-driven readout mode. The chips were tested with injected pulses,  $\alpha$  particles from <sup>241</sup>Am, and a Fe-ion beam of 350 MeV/u, coupled with single GEM. The position resolution, rate capability and reconstruction efficiency for the beam particles were characterized.

CEE at HIFRL-CSR		Beam Monitor of CEE	
Heavy Ion Research Facility in Lanzhou Cooler-Storage-Ring system	<ul> <li>CSR External-Target Experiment</li> <li>Study the properties of cold nuclear matter at high baryonic density</li> <li>Construction time: 2020-01 to 2024-12</li> <li>Lowest (highest) beam energy: 0.3 (2.8) GeV/u</li> <li>Maximum system: U+U</li> <li>Maximum event rate: 10<sup>4</sup> s<sup>-1</sup></li> </ul>		<ul> <li>Placed upstream of the fixed target</li> <li>Measure the position of each beam particle</li> <li>Used in vertex reconstruction (combined with TPC and MWDC)</li> <li>Main design parameters: <ul> <li>Position resolution : 50 μm</li> <li>Minimum time separation of two particles: 1 μs</li> </ul> </li> </ul>
L Low Energy	ZDC		• Sonsitivo aroa: $30 \times 30$ mm <sup>2</sup>



- Two field cages in a gas vessel, each measuring 1-D transverse coordinate
- Custom-designed Topmetal chip as anode for charge sensing and readout
- Direct charge sensing for heavy ionizing particles e.g. U
- Single-layer GEM for less ionizing particle e.g. C

## **Topmetal-CEEv1 chip**



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the main features of the Topinetal-CEEVT chip.	
Feature size	130 nm
Chip area	4.2 mm ×19 mm
Number of pixels	$1 \times 180$
Pixel pitch	100 µm
CCE size	1 mm ×89 μm
Shaping time (tunable)	$\sim 0.5~\mu s$ to 2 ms
Peaking time	$\sim 100 \text{ ns}$
Readout scheme	Data-driven readout
Readout time	25 ns/pixel
Amplitude measurement	TOT method



### **Tests with injected pulses**

Key characteristics of the electronics, including the noise, threshold and gain of the CSA and the ToT output, are assessed by means of injected pulse signals through the guard-ring capacitance.



### **Tests with Fe-ion beam**



Typical event with  $\Delta V_{GEM}$  = 450 V (top), 350 V (bottom),

threshold of about 28k  $e^-$ , in a gas mixture of Ar(70%)

E<sub>Drift</sub> = 300 V/cm, E<sub>Induction</sub> = 1000 V/cm and pixel

+ CO<sub>2</sub>(30%).

The photo of the detector. The bonding board is placed The setup of the beam test. The energy of the Fe-ion beam is under single GEM, acting as the anode of the field cage. 350 MeV/u, with the density varying between about 10<sup>4</sup> to 10<sup>6</sup> pps.



# Tests with <sup>241</sup>Am $\alpha$ particles

At the time of the beam test, the ToT function was not available in the readout system. The ToT was later tested with <sup>241</sup>Am  $\alpha$  particles.

To T of the pixels in a typical event with  $\Delta V_{GEM}$  = 475 V, E<sub>Drift</sub> = 300 V/cm, E<sub>Induction</sub> = 1000 V/cm and pixel threshold of about 10k  $e^-$ . Amplitude 0.1 V =  $\sim$ 70k  $e^{-}$ .



Residue [100µm]

determined by the

other two columns of

pixels.  $\Delta V_{GEM} = 350 \text{ V}.$ 



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